LETTER TO THE EDITOR

## The Catalytic Decomposition of Hydrogen Peroxide Vapor by Nickel Oxides and Promoted Nickel Oxides

In previous papers studies of the decomposition of hydrogen peroxide vapor on metallic oxides (1) and mixed metallic  $oxides$  (2) have been reported. It was shown that the order of catalytic efficiency of a range of metallic oxides could be given as follows :

## $Mn_2O_3 > PbO > Ag_2O > CoO > Cu_2O > NiO >$  $Fe<sub>2</sub>O<sub>3</sub> > CdO \gg ZnO = MgO > \alpha-Al<sub>2</sub>O$

Nickel oxide, an oxide of lower efficiency, seemed to be a convenient catalyst for further study. Since, nickel oxide has been examined in the pure state and with controlled impurity additions as a catalyst for nitrous oxide decomposition (3) and for the carbon monoxide/oxygen reaction  $(4)$ . The present work describes the catalytic behavior of this oxide in various states of preparation-as films on glass and on nickel metal as well as the highly compressed bulk oxide, prepared pure or with addition of lithium oxide or gallium oxide as impurities.

The flow system already described (1) was used without modification.

Laporte's stabilizer-free hydrogen peroxide  $(86-90\% \text{ w/w})$  was used after concentration to 99.9%  $(n_D^{25} = 1.4066)$  at 55-65" and 50-70 mm Hg pressure. Nickel oxide was prepared by igniting A.R. nickel nitrate in air at  $400^\circ$ , grinding to pass  $300$ mesh B.S. sieve, then further igniting at the same temperature for several hours. This gave a black oxide of composition  $NiO<sub>1.16</sub>$ . Firing this for 24 hours in air gave a pale-green oxide of composition  $\text{NiO}_{1.00}$ . However this material  $(5)$  may still contain  $0.02$  to  $0.2\%$  excess oxygen.

The black oxide showed a marked dependence of paramagnetic susceptibility on field strength at room temperature  $(\psi =$  $18.0 \times 10^{-6}$  c.g.s. units at 1,500 öersteds:  $12.7 \times 10^{-6}$  c.g.s. units at 10,600 öersteds). The green oxide gave negligible dependency,  $\psi = 9.63 \times 10^{-6}$  and  $10.05 \times 10^{-6}$ c.g.s. units at the above field strengths. X-ray analysis showed no nickel metal lines but the black oxide unit cell was slightly smaller (4.16OA) than for the green material  $[4.183\text{\AA}, \text{c.f.}$  Fensham  $(6)$  $4.181\text{\AA}$ ].

Gallium oxide was prepared by decomposition of the "Specpure" nitrate at 800" and lithium oxide by heating the A.R. carbonate at 800° in a stream of nitrogen.

Mixed oxides were prepared by intimately grinding the required amounts for 4 hr and annealing at 650" for 6 hr. After firing,  $NiO/Ga<sub>2</sub>O<sub>3</sub>$  mixtures remained apple-green in color, while  $Li<sub>2</sub>O$  additions gave black oxides. Oxide samples were pressed to  $10 \times 25 \times 2$  mm slips in a highly polished chrome steel die at 17.5 tons/sq. inch (giving 90% of crystal density).

Glass-supported nickel oxide films were prepared by evaporating nickel at  $10^{-5}$  mm and  $-183^\circ$  from a "Specpure" wire. The deposits were  $5-12~\mu$  thick before oxidation in air at room temperature. For films on metal, "Specpure" nickel was cut to the same size as the oxide slips, degreased, and allowed to oxidize in air at the working temperatures. The metal was bright and the oxide films 100-5OOA thick as determined by coulometric reduction on parallel samples.

All the nickel oxide preparations gave a steady efficiency after about one hour of exposure to  $H_2O_2$  vapor. Black nickel oxide on first exposure gave a high decomposition rate but over the course of runs at 100' and 38" the color changed, in time, to a murky green and the efficiency level tended to that of the stoichiometric bulk oxide. This deterioration in activity is probably due to a reduction of oxygen content on exposure to  $H_2O_2$  which superficially reduces reaction initiation sites such as Oand  $O_2$ . The  $Ga_2O_3$  and  $Li_2O$ -containing oxides gave steady, stable activities almost immediately and there was no tendency for the  $Li<sub>2</sub>O$ -doped samples to change from black to green.

The temperature dependence of the reaction rate with nickel oxide on flashed films was examined in the region  $60^{\circ}$ -160 $^{\circ}$ with an  $H<sub>2</sub>O<sub>2</sub>$  partial pressure of 0.88 mm Hg. An Arrhenius plot of these results is shown in Fig. 1 for a nickel flashed film



FIQ. 1. Arrhenius plot, flashed nickel film.

5.7  $\mu$  thick. The slope of this line corresponds to an activation energy of 11.0  $\pm$  0.5 kcal/mole. In the same temperature range the nickel oxide on metal slip gave an experimental  $E_A = 13.0 \pm 0.5$  kcal/ mole.

In terms of steady decomposition values, the bulk NiO samples containing 0.094 to 2.1 mole  $\%$  Ga<sub>2</sub>O<sub>3</sub> were less active catalysts than those containing corresponding amounts of  $Li<sub>2</sub>O$ . The effect of adding  $Li<sup>+</sup>$ ions to the stoichiometric oxide was to increase the decomposition as the Li+ content increased, while adding more than 0.004 mole  $\%$  Ga<sub>2</sub>O<sub>3</sub> gave, at each temperature, a slightly improved activity which was independent of the amount of  $Ga<sub>2</sub>O<sub>3</sub>$  added. Table 1 shows the steady activity levels obtained with pure and doped NiO samples along with their surface areas  $[BET:C<sub>2</sub>H<sub>4</sub>:$  $-183^{\circ}$  (7)] determined after exposure to

 $H_2O_2.$ TABLE 1

CATALYTIC ACTIVITIES FROM 38" TO 136" OF NICKEL OXIDE AND DOPED NICKEL OXIDES IN  $H_2O_2$  DECOMPOSITION<sup>a</sup>

Catalyst	Percentage decomposition				Surface
	$38^\circ$	en°	$100^\circ$	$136^\circ$	area (c <sub>m</sub> <sup>2</sup> )
NiO	8.0	21.0	- 50.0	65.0	184
$\rm NiO$ $+$ $2.4$ mole% $\operatorname{Li}_2O$			$31.5$ $43.5$ $77.5$ $97.0$		166
$\rm NiO$ $+$ $2.1$ mole $\%$ Ga <sub>2</sub> O <sub>3</sub>	$-$	30.0	$60.6$ 78.0		157

<sup>a</sup> Partial pressure  $H_2O_2 = 0.96$  mm Hg.

The kinetics of the decomposition were studied on the 2.4 mole  $\%$  Li<sub>2</sub>O and 2.1 mole  $\%$  Ga<sub>2</sub>O<sub>3</sub> mixtures with an initial  $H<sub>2</sub>O<sub>2</sub>$  partial pressure of 0.96 mm Hg. The two catalysts behaved similarly on making fast concentration decrease, in that the same fraction of  $H_2O_2$  vapor was decomposed at 0.96, 1.64, and 0.32 mm, apart from a quickly damped cyclic variation on making the initial changes. The reversal from 0.32 mm to 0.96 mm was accompanied by a minor efficiency drop which was slightly more pronounced with Ga<sup>3+</sup> as the impurity.

The influence of oxygen and water partial pressures, was determined, as described earlier  $(1)$ , for nickel oxide on metal slip, green nickel oxide, and for 2.4 mole  $\%$  Li<sub>2</sub>O and 2.1 mole  $\%$  Ga<sub>2</sub>O<sub>3</sub> additions. These kinetic studies gave the following rate expression :

$$
r = k(p_{\rm H_2O_2}) \cdot (p_{\rm O_2})^{1/8} \cdot (p_{\rm H_2O})^{-1/2}
$$

The kinetic results, together with the activity figures for the doped nickel oxides, are in harmony with earlier proposals (I) for the classification of inorganic oxide catalysts, in  $H<sub>2</sub>O<sub>2</sub>$  decomposition, into activity groups which are related by the nature of the defect solid lattice.

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